

**Preliminary communication**

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**Organosilicon compounds**

**CVIII\*. Carbon-13 and silicon-29 NMR spectra of phenyl- and benzyl-substituted silanes**

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**SUMMARY**

<sup>29</sup>Si and <sup>13</sup>C NMR chemical shifts in Si-substituted phenyl- and benzylsilanes are determined and intercorrelated.

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It was recently shown<sup>2</sup> that the electronic interactions between a benzene ring and MR<sub>3</sub> or CH<sub>2</sub>MR<sub>3</sub> substituents are usefully studied by methods which do not involve the need for other ring substituents acting as a probe. <sup>13</sup>C and <sup>29</sup>Si NMR spectra meet this requirement, furthermore aromatic carbon-13 chemical shifts correlate with structural parameters<sup>3</sup>. For this reason the data presented in Table 1 were obtained using the spectrometer and experimental techniques previously described<sup>6,7</sup>.

Unfortunately, the latest and apparently best correlations<sup>8</sup> cannot be applied to our results without reservation because they were obtained under experimental conditions (10 mol % solutions) not attainable in our laboratories at present. The average value of the apparently constant difference  $\Delta\delta(C_p)$  between the chemical shifts in C<sub>6</sub>H<sub>5</sub>CH<sub>2</sub>X and C<sub>6</sub>H<sub>5</sub>X (-6.02 ppm) corresponds<sup>8</sup> ( $\pm 20\%$  error due to solvent effects<sup>8</sup>) to the total charge density in C<sub>6</sub>H<sub>5</sub>CH<sub>2</sub>X compounds being shifted by 0.02 units to more negative values compared with C<sub>6</sub>H<sub>5</sub>X compounds for the same X. Similarly, the  $\sigma^+$  constants are 0.5 units more negative for CH<sub>2</sub>X groups as compared with X groups. These findings agree well

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\* For part CVII see ref. 1.

TABLE I

CARBON-13 AND SILICON-29 NMR DATA FOR BENZYL-, PHENYL- AND METHYLSILANES AND  $\sigma_p$  VALUES OF VARIOUS SILYL GROUPS<sup>a</sup>

Substituent X	$C_6H_5CH_2X$		$C_6H_5X$		$CH_3X$		$\Delta\delta(C_p)^d$	$\Delta\delta(Si)^c$	$\Delta_0\delta(Si)^b$	$\sigma_p(DM)^e$	$\sigma_p(NMR)^f$
	$\delta(C_p)^g$	$\delta(Si)^g$	$\delta(C_p)^g$	$\delta(Si)^g$	$\delta(Si)^g$	$\delta(Si)^g$					
SiMe <sub>3</sub>	123.1	0.4	128.3	-5.1	0.0 <sup>h</sup>	0.4	5.5	0.4	-0.05	0.06	
SiMe <sub>2</sub> Cl	124.1	26.6			29.9	-3.3			0.30	0.15	
SiMeCl <sub>2</sub>	125.3	26.9	131.0	17.9	31.8	-4.9	9.0	-5.7	0.41	0.42	
SiCl <sub>3</sub>	126.0	7.2	132.8	-0.8	12.2	-5.0	8.0	-6.8	0.43	0.37	
SiMe <sub>2</sub> (OEt)	123.4	11.7	129.0	5.1	13.5	-1.8	6.6	-5.6	(0.12) <sup>i</sup>	(0.10) <sup>i</sup>	
SiMe(OEt) <sub>2</sub>	123.6	-11.9	128.8	-20.2	-6.1	-5.8	8.3	-5.2	(0.18) <sup>i</sup>	(0.15) <sup>i</sup>	
Si(OEt) <sub>3</sub>	123.6	-52.7	129.5	-59.4	-44.5	-8.2	6.7	-5.9	(0.19) <sup>i</sup>	(0.10) <sup>i</sup>	
SiMe <sub>2</sub> F	124.1	27.4	130.1	19.8	(30.5) <sup>j</sup>	(-3.1)	7.6	-6.0	0.23	0.15	
SiMeF <sub>2</sub>	124.6	-2.9	131.5	-12.4	(4.5) <sup>j</sup>	(-7.4)	9.5	-6.9	0.40	0.28	
SiF <sub>3</sub>	125.8	-64.2	132.7	-73.2	k		9.0	-6.9	0.51	0.51	
SiH <sub>3</sub>	124.9	-56.0	129.4	-59.9	k		3.9	-4.5	0.07	0.10	

<sup>a</sup> <sup>13</sup>C and <sup>29</sup>Si chemical shifts were measured at 15.09 and 11.91 MHz, resp. in neat liquids relative to external tetramethylsilane. The shifts are given in  $\delta$  scale, i.e. in ppm units with positive values corresponding to lower shielding, the maximum error  $\pm 0.3$  ppm. <sup>b</sup> C chemical shift of benzene is 128.1 ppm in this scale. <sup>c</sup> Substituent effect of  $C_6H_5$  group determined as  $\Delta_0\delta(Si) = \delta(Si)(C_6H_5CH_2X) - \delta(Si)(CH_3X)$ . <sup>d</sup>  $\Delta\delta(C_p) = \delta(Si)(C_6H_5CH_2X) - \delta(Si)(C_6H_5X)$ . <sup>e</sup>  $\Delta\delta(Si) = \delta(Si)(C_6H_5CH_2X) - \delta(Si)(C_6H_5X)$ . <sup>f</sup>  $\Delta\delta(C_p) = \delta(C_p)(C_6H_5CH_2X) - \delta(C_p)(C_6H_5X)$ . <sup>g</sup>  $\sigma_p$  values determined from dipole moments of *p*-CH<sub>3</sub>C<sub>6</sub>H<sub>4</sub>X in ref. 4. <sup>h</sup>  $\sigma_p$  values determined from NMR  $J(^{13}C-H)$  coupling in *p*-CH<sub>3</sub>C<sub>6</sub>H<sub>4</sub>X in ref. 4. <sup>i</sup> Reference compound. <sup>j</sup> Value for analogous methoxy derivative. <sup>k</sup> Taken from ref. 5. <sup>l</sup> Not available.

with the established (see e.g. ref.2) electron-accepting properties of  $\text{SiR}_3$  groups and electron-releasing ability of  $\text{CH}_2\text{SiR}_3$  groups and with the charges calculated by Nagy *et al.*<sup>9,10</sup> The present data show an interesting linear correlation between  $\delta(\text{Si})(\text{C}_6\text{H}_5\text{CH}_2\text{X})$  and  $\delta(\text{Si})(\text{C}_6\text{H}_5\text{X})$  characterized by unit slope and correlation coefficient of 0.999 (ten data points). This and other correlations involving  $\delta(\text{C}_p)$  and  $\sigma^+$  or  $\sigma_p$  constants will be discussed in a forthcoming paper.

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